

Strain engineering in metal halide perovskite materials and devices: Influence on stability and optoelectronic properties

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ABSTRACT

Metal halide perovskites (MHPs) have been extensively studied for their promising applications in solar cells and other devices due to their extraordinary optoelectronic properties, low cost, and easy fabrication by versatile processes. Different from bulk crystals grown from solutions, polycrystalline perovskite films deposited on substrates generally are strained due to multiple mechanisms, which significantly impact their optoelectronic properties, defect physics, and photostability. The fabrication and operation of perovskite solar panels inevitably introduce strains in perovskite. Strain has been broadly applied to stabilize the photoactive phase of several perovskite compositions that would otherwise show a thermodynamically stable photoinactive phase at room temperature. There is increasing research on strain engineering of MHPs to enhance device performance. However, a systematic review and understanding of strain engineering in MHP is still lacking. Herein, an overview of strain engineering on MHP materials and solar cells is provided. In this review, we start with a general review on strain in semiconductors, including the characteristics of strain, characterization techniques, and the effects of strain on the lattice structure, electronic, and optical properties of semiconductors. We then summarize progress in understanding the generation of strain categorized by local and global strains and their impacts on the multi-faceted properties of MHPs, including phase stability, photostability, and other optoelectronic properties. Both positive and negative impacts have been observed on these properties. Strain engineering has shown to be promising in making much more efficient and stable perovskite solar cells.

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I. INTRODUCTION

Metal halide perovskites (MHPs) have attracted much attention due to their high defect tolerance, low trap density, high optical absorption coefficients, high carrier mobility, long carrier lifetime, and tunable bandgap.^{1–6} The low-cost, low-temperature scalable solution fabrication processes have also promoted the wide application of MHPs in photovoltaics, light-emitting diodes, photodetectors, lasers, and ion radiation detectors.^{7–12} It is notable that the power conversion efficiency (PCE) of single-junction perovskite solar cells has been rapidly enhanced from 3.8% to 25.5% in 10 years,^{13,14} which is higher than those of other thin film photovoltaics such as CdTe and CIGS,

and is approaching the best efficiency of monocrystalline single crystal silicon solar cells.

Strain, as one very important variable that defines the material's deformation, plays an important role in the fundamental properties and application of semiconductors, which should impact MHPs. The effect of strain on semiconductor properties has been widely exploited since the influence of strain on the intrinsic mobility of Si was first investigated in the early 1950s.^{15–18} It developed into a field of strain engineering, which refers to the method of improving one or more properties of materials through mechanical deformations. Strain is a tensor to describe and quantify the deformation of a material. Generally, there are components along the diagonal (normal strain) and off diagonal terms (shear strain) in a strain tensor. Strain in materials can be classified into four types according to the loading applied to the material [Fig. 1(a)]: uniaxial strain (a material is stretched or compressed along one direction), biaxial strain (a material is pulled or compressed in two directions), hydrostatic strain (the deformation of a material in all normal directions under loading is equal and no shear components and thereby only changes the volume of the material, but not in shape), and shear strain (the deformation of a material results from forces acting along the material's two parallel surfaces.); meanwhile, due to Poisson's effect, strain was also induced in non-loading direction. A deformed material can have a combination of these different types of strain. Based on the distribution range of the strain, it can also be classified as global and local strains. A global strain means that the strain is introduced across the entire material, which mainly originates from lattice mismatch or thermal expansion coefficient mismatch between materials and the substrates [Figs. 1(b)–1(c)]. In epitaxial growth of materials, if the lattice constant (α_1) of material 1 is larger/smaller than that of material 2 (α_2), an in-plane biaxial compressive/tensile strain is induced in material 1. For materials involving in thermal annealing processes, if the thermal expansion coefficient of material 1 (α_1) is larger/smaller than that of material 2 (α_2), an in-plane biaxial tensile/compressive strain is induced in material 1. The deformation of substrates will also induce strain in pre-deposited materials. For example, bending the substrates could induce in-plane uniaxial tensile/compressive strain related to the bending direction in the materials [Fig. 1(d)]. Elongating the substrate could also induce in-plane uniaxial tensile strain in pre-deposited materials [Fig. 1(e)]. Although the range of global strain is the entire material, the global strain can be either homogeneous or inhomogeneous across the whole material. For example, thermal gradient induces inhomogeneous global strain in materials. In the epitaxial growth of semiconductors, the largest strain is at the heteroepitaxial interface, and strain decreases at the regions away from the interface. As the strain energy increases, it would become energetically favorable to form dislocations. Strain relaxation occurs along with the generation of these dislocations. While bending materials to induce uniaxial strain, all materials on one side of the neutral axis are under tension, while those on the other side are under compression, and there is no strain along the neutral axis. The location of neutral axis of the layered structure depends on the sample structure, including the thicknesses and mechanical properties of functional layers and substrates.¹⁹ The bending strain is a function of bending curvature and the distance from the neutral axis: $\varepsilon = h/\rho$, where ρ is the bending curvature of the material and h is the distance from the neutral axis. So, there is a strain gradient from top to bottom across the cross-section, and the maximum strains occur on the material surfaces. A local strain means that the strain is not uniform through the material, only locating in certain

regions. As shown in Fig. 1(f), depositing materials on elastically pre-deformed substrates first and then releasing the substrates result in a local strain in the wrinkling or bucking regions of the material. Besides, local strain can also be induced by elemental doping or alloying due to the size difference between the dopant and the host atoms [Fig. 1(g)].

Strain in semiconductors is embodied in the extension or shortening of chemical bond lengths, and/or the change of chemical bond angles, which leads to changes in crystal volume and/or the distortion of the lattice of crystals. Such a distortion can cause a phase transition. Theoretical and experimental work has demonstrated that strain could change the crystal structure of Si, Ge, and two-dimensional transition metal chalcogenides, resulting in a phase transition.^{20–23} For example, a small (0.2%) tensile strain has been shown to transform hexagonal semiconducting MoTe_2 (~ 1 eV bandgap) into metallic phase (distorted octahedra).²³ The changed lattice constant by strain should change the interatomic interaction as well, resulting in a change in bandgap. For example, in most semiconductors, a compressive strain would make the bonding and antibonding energy states further apart in energy, resulting in a wider bandgap. Furthermore, the influence of strain on the conduction band and valence band may be different, and thus induces direct-indirect transitions in semiconductors such as two dimensional MoS_2 .^{24–26} At the same time, the changed band structure in strained semiconductors inevitably impacts the curvature of the dispersion relation at the band edges. The effective mass (m^*) of carriers is determined by the band curvature and thus changes with strain, which also impacts carrier mobilities. For example, the carrier mobility in Si NWs is very responsive to strain and can be enhanced or reduced by a factor 2–5 for moderate uniaxial strains within the $\pm 2\%$ range due to the changes in the effective mass (m^*) of carriers.²⁴ Strain can also impact the defect density in materials. Strain could change the vacancies concentration in semiconductors by changing its formation energy. For example, the tensile strained MoS_2 has a decreased bandgap and increased S vacancy concentrations,²⁷ leading to an unprecedentedly catalytic activity of MoS_2 for the hydrogen evolution reaction. Strain has also been proved to control the O vacancy concentrations by changing the formation energy of O vacancies in transition-metal oxide materials.^{28,29} For example, the oxygen content of perovskite-based strontium cobaltite (SrCoO_{3-x}) shifts from $x < 0.1$ to $x \sim 0.25$ when modest amounts of tensile strain over 1% was induced in materials.²⁸

Strain engineering is an effective tool to tune material properties for its pronounced impact on lattices. Notably, strain in semiconductors is inevitable introduced in material fabrication for either lattice mismatch with substrates or lattice expansion/contraction during thermal annealing process. Hence, studying the strain effect would provide insight in understanding and designing MHPs for solar cell applications. Compared with traditional semiconductors such as Si and GaAs, MHPs have a relatively low Young's modulus (10–30 GPa) and a large ratio of bulk modulus to shear modulus (bulk modulus/shear modulus > 1.75), which may enable flexible perovskite devices, including flexible solar cells, light emitting diodes, and detectors.^{30–33} The soft nature of MHPs makes them more sensitive to stress than other semiconductor materials, since the strain is greater under the same stress in MHPs. Residual tensile strain has been commonly observed in thermally annealed perovskite films.^{34,35} Changing local strain using alloying has been shown to successfully enhance the performance of perovskite solar cells, including efficiency and stability.³⁶ Therefore,

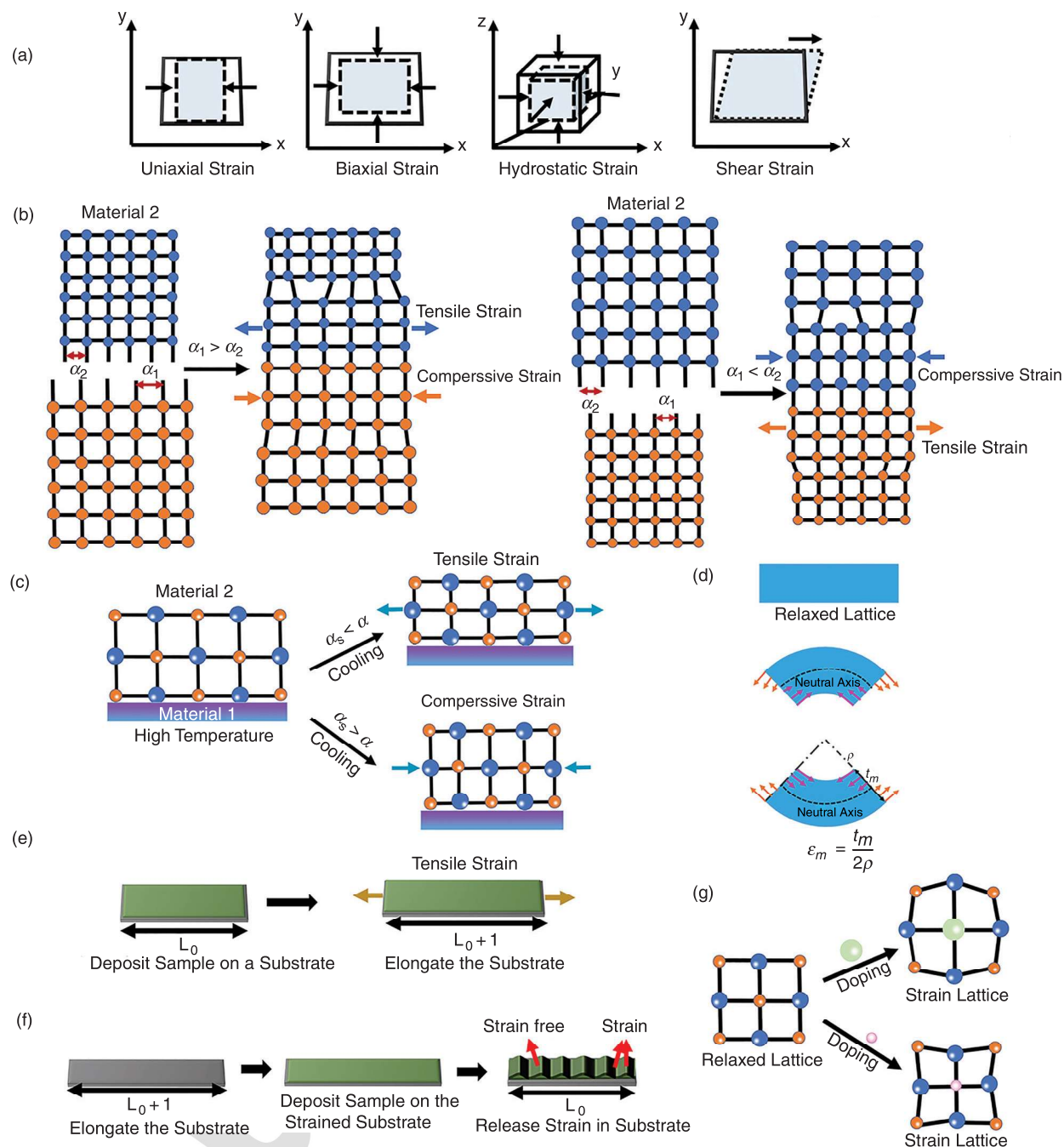


FIG. 1. (a) Schematic of $\langle 100 \rangle$ uniaxial, (x-y) plane biaxial, and hydrostatic strain. Schematic of methods to induce strain: (b) lattice mismatch; (c) thermal expansion coefficients mismatch; (d) bending the substrates; (e) elongating substrate to induce uniaxial tensile strain; (f) releasing strain in the pre-deformed substrate; (g) chemical doping or substitution or absorption.

184 strain engineering in perovskite has aroused great interest in research.
 185 This review summarizes the progress in understanding the effect of
 186 strain on phase stability, bandgap, and trap density in MHPs and
 187 future research prospects.

II. STRAIN CHARACTERIZATION

The first step to understand the impact of strain on materials is
 to accurately characterize the strain. The strain in semiconductors can

be directly characterized through the lattice distortion by x-ray diffraction (XRD) and transmission electron microscopy (TEM) measurements. And it can also be indirectly quantified through the changes of the optical properties of semiconductors that are characterized by Raman spectroscopy. Here, we summarize these three commonly used techniques for strain characterizations.

197 A. X-ray diffraction

XRD technique is a widely used method to characterize lattice structures with high resolutions, which can directly measure the global strain without the destruction of the sample.³⁷ Strain in materials will induce lattice contraction/expansion or tilting. Correspondingly, XRD peaks shift to a larger/smaller diffraction angle under compressive/tensile strain. In addition, the diffraction peak is broadened when the strain is not homogeneous in materials. Moreover, x-ray microdiffraction method was employed to measure the strain with a sub-micro spatial resolution, which is three orders of magnitude higher than that of conventional XRD techniques, and the strain-resolution ($\Delta\epsilon$) reaches 10^{-5} .^{37,38} Generally, x-ray technique requires a volume of materials (more than tenths of a gram), thus it is unfeasible for the analysis of the lattice information of individual nanosized materials.

211 B. TEM

TEM technique is a powerful technique to characterize strain, which typically has a spatial resolution up to 0.1–0.2 nm with a precision of 10^{-3} .³⁹ Strain is characterized by measuring the changes in local lattice constants and orientations of the lattice planes with respect to reference materials. Considering the immediate damage of the materials by the energetic electron beam, cryo-TEM has been applied in the structural characterization of materials that are prone to be damaged by electron beam (e.g., perovskites).^{40,41} In addition, low-dose scanning TEM is also used to determine the microstructure of perovskite thin films to slow down the degradation from the same total electron beam.⁴² Notably, it is still challenging to prepare TEM samples, which should be thin enough to become sufficiently transparent to electrons. The samples are usually thinned by ion-beams, which may introduce damage or changes to the strain of samples, leading to an inaccurate characterization of the strain.^{39,43}

227 C. Raman spectroscopy

Raman spectroscopy is a nondestructive chemical analysis technique to study the stress/strain of materials based on the interaction of the laser with the chemical bonds in a material.⁴⁴ Strain in materials leads to the changes in lattice vibration (phonon), which can be detected by Raman spectroscopy. The vibrational frequency shift is shown to be proportional to strain magnitude in materials.^{45–49} In tensile strained materials, phonon softens and the vibrational frequency decreases in the strain direction, leading to a red-shifting of the Raman peaks. Conversely, compressive strain leads to phonon hardening and a blue-shifting of Raman peaks.⁴⁵ The capability of mapping using Raman allows the mapping of strain with a spatial resolution better than $0.5\ \mu\text{m}$ and a sensitivity better than 10^{-3} .⁴⁴ Also, it does not require sophisticated sample preparation, ensuring undistorted strain states in materials. In Raman spectroscopy, great consideration should be paid to the excitation laser wavelength and intensity, because they affect both the Raman signal depth profile and

intensity.⁵⁰ In addition, low-power laser is needed to avoid laser-heating effects and sample degradation. For example, laser excitation power with less than $10\ \mu\text{W}$ on spot diameter of $1\ \mu\text{m}$ was reported in Raman measurement of laser-sensitive perovskites, which is 2 orders of magnitude lower than $\mu\text{c-Si:H}$ thin films.^{51,52}

It should be noted that the Raman peak shifting is not only related to the strain in materials; changes in physical or chemical environments will also cause the shifts of Raman peaks. The dependence of peak frequency and full width at half-maximum (FWHM) on defect density and grain sizes have also been demonstrated.⁵³ Therefore, it is important to control experimental conditions precisely and combine other strain characterization methods to characterize strain in materials.

III. STRAIN ENGINEERING IN METAL HALIDE PEROVSKITES

A. Strain in perovskites

1. Local strain

In ABX_3 structured perovskites, the mismatch between the A cations and BX_6 cage size leads to cage distortions and BX_6 octahedra tilting, inducing local strain in perovskites. Goldschmidt's tolerance factor (τ) is widely used in predicting the structural stability and octahedral factor (μ) defines the stability of the BX_6 octahedron.⁵⁴ Both factors are necessary but not sufficient to predict perovskite structural formability. Tolerance factor τ can be expressed by the equation $\tau = \frac{R_A + R_X}{\sqrt{2}(R_B + R_X)}$, where R_A , R_B , and R_X are the ionic radii of A cation (methylammonium- MA^+ , formamidinium- FA^+ , Cesium- Cs^+ , etc.), B cation (lead- Pb^{2+} , tin- Sn^{2+} , etc.), and X anion (iodide- I^- , bromide- Br^- , chloride- Cl^- , etc.), respectively. Octahedral factor μ is the ratio of the ionic radius of B and X atoms: $\mu = \frac{R_B}{R_X}$. Perovskites with τ between 0.8 and 1.0 and μ between 0.44 and 0.90 are reported to be thermodynamically stable at room temperature.^{54,55} However, perovskites with τ out of this range, such as FAPbI_3 ($\tau > 1$) and CsPbI_3 ($\tau < 0.8$), tend to form the photoinactive hexagonal δ -phase at room temperature. During the spontaneous phase transformation from photoactive perovskite phases to δ -phases, strain is also induced in crystals due to spatial heterogeneity. Saidaminov *et al.* claimed the existence of local strain in black-phase FAPbI_3 (α - FAPbI_3), and it would be released by point defect formations.³⁶ Conversely, Zheng *et al.* proposed that α - FAPbI_3 has an anisotropic strained lattice, and the strain in the (111) plane is greater, which drives phase transformation into the strain-free δ -phase.⁵⁶ The unfavorable residual strain in FAPbI_3 lattice could be released by the substitution or doping of foreign ions (such as MA^+ , Cs^+ , Ca^{2+} , Cl^- or Br^-) to form alloyed perovskites.^{36,56–59} However, composition inhomogeneity in alloyed perovskites also leads to local strains. For example, I–Br mixed halide perovskites tend to form I-rich regions and Br-rich regions under illumination when the content of Br is larger than 20%,⁶⁰ which would induce local strain in perovskites. In polycrystalline perovskite films, grain boundaries are known as reservoirs of defects and likely to change the strain state in their vicinity because of different atomic spacing and structure compared to their perfect crystal structure.⁶¹ In addition, light-induced strain is also reported in $\text{FA}_{0.7}\text{MA}_{0.25}\text{Cs}_{0.05}\text{PbI}_3$ and MAPbI_3 films,^{62,63} originating from photothermal-induced expansion in the perovskite films. Solid material formation kinetics also impact the residual strain in films or crystals. For example, strain can be induced in solution-processed

AQ3

films due to solvent removal, phase transformation from intermediate phases, film shrinkage, and volatile component (MA^+ , Cl^-) removal during annealing.⁶⁴ Therefore, strain distribution is likely to be inhomogeneous at atomic scale in perovskite materials. Jones *et al.* probed local strain in MAPbI_3 perovskite thin films by scanning micro-XRD (μXRD) and high-resolution TEM. The spatial resolution of the μXRD was $\sim 2.5\ \mu\text{m}$. Subtle shifts in the $\langle 220 \rangle$ and $\langle 222 \rangle$ diffraction peaks position and broadening illustrated the occurrence of local structural heterogeneity on the scale of beam resolution. The strain map for the $\langle 220 \rangle$ diffraction peak showed that the magnitude of strain is 0.1%–0.2%. They also collected the high-resolution TEM images from a $70 \times 70\ \text{nm}^2$ region. The electron dose rate of TEM was $\sim 1\text{--}4\ \text{electrons}\ \text{\AA}^{-2}\ \text{s}^{-1}$. There were different diffraction patterns from various $10 \times 10\ \text{nm}^2$ regions of the TEM images, demonstrating the presence of structural heterogeneity in nanoscales.⁶⁵ Local strain in perovskite films is very complicated and thus needs a much more comprehensive characterization to provide insight into how the local strain is controlled by film formation kinetics, material composition, material morphology, etc.

2. Global strain

a. Thermal effect. Thermal expansion coefficient mismatch between perovskites and substrates introduces global strain in perovskite films during their fabrication processes. The thermal expansion coefficients of perovskites are approximately one order of magnitude higher than most of their substrates and charge transport materials (e.g., ITO glass, Si, SnO_2 , TiO_2 , PTAA, etc.).^{34,35,66–70} In 2017, Zhao *et al.* first discovered that MHP films fabricated by all methods that involve thermal annealing, including one-step spin-coating, two-step spin-coating, and doctor blade-coating, were strained, and the flat polycrystalline MAPbI_3 films have an in-plane tensile strain of 0.47% after cooling down from 100°C .³⁴ The clamp effect of the substrate also induces a compressive strain along the out-of-plane direction due to the Poisson effect. Rolston *et al.* also reported a residual in-plane tensile stresses in perovskite films in excess of 50 MPa, which is high enough to deform copper.³⁵ Steele *et al.* used synchrotron-based, grazing incidence, wide-angle x-ray scattering to monitor the crystal distortion process in CsPbI_3 thin film after rapidly cooling it from 330°C to 100°C and observed a $\sim 1\%$ in-plane tensile strain.⁷¹ The magnitude of strain from thermal expansion coefficient mismatch directly correlates with the annealing temperature of perovskite films. Reducing the film stress and strain can be accomplished by decreasing annealing temperatures or selecting substrates with large thermal expansion coefficients.^{35,72} In addition, the residual tensile strain can be compensated by introducing a compressive strain. The poly [5,5-bis(2-butyloctyl) (2,2-bithiophene)-4,4'-dicarboxylate-alt-5,5'-2,2'-bithiophene] (PDCBT), possessing a higher thermal expansion coefficient than perovskites, has been used as the hole transport layer in n-i-p solar cell structure. The tensile strain in PSCs was compensated by elevating the processing temperature of the hole-transport layer, leading to a non-strained or even compressively strained CsPbI_2Br perovskite film.⁷²

b. The epitaxial growth of perovskite. In perovskite solar cells, lattice mismatch-induced strain is not inevitable, because the growth of perovskite on charge transport layers or charge transport layers on

perovskite is not epitaxial in most of cases.^{73–76} However, there are cases where epitaxial growth can occur. The horizontal growth of strained CsPbBr_3 microwires on sapphire substrates has already been reported, where the CsPbBr_3 (110) plane grows on the sapphire (0001) plane and the in-plane lattice parameter of CsPbBr_3 is enlarged by $\sim 2\%$ at the interface with sapphire.⁷⁴ Chen *et al.* reported the strained epitaxial growth of halide perovskite single-crystal thin films on lattice-mismatched halide perovskite substrates.⁷³ They investigated the strain in $\alpha\text{-FAPbI}_3$ that was epitaxially grown on $\text{MAPbCl}_x\text{Br}_{3-x}$ single crystal substrates with different compositions. An in-plane biaxial compressive strain as high as 2.4% was detected in the epitaxial $\alpha\text{-FAPbI}_3$. Chen *et al.* studied confocal photoluminescence spectra at different locations in an $\alpha\text{-FAPbI}_3$ film of around $3\ \mu\text{m}$ thick grown on a $\text{MAPbCl}_{1.5}\text{Br}_{1.5}$ single crystal substrate and found that the 2.4% compressive strain decreased to near zero from the interface of $\alpha\text{-FAPbI}_3/\text{MAPbCl}_{1.5}\text{Br}_{1.5}$ to the top surface of $\alpha\text{-FAPbI}_3$. It was because that strain in the epitaxial $\alpha\text{-FAPbI}_3$ is determined not only by the lattice mismatch between the epilayer and substrate, but also the strain relaxation mechanisms. The thickness-dependent in-plane XRD showed that the critical thickness of the 2.4% compressive strained $\alpha\text{-FAPbI}_3$ film is much smaller than $3\ \mu\text{m}$, which is close to 100 nm.

In addition, the epitaxial growth of $\alpha\text{-CsPbBr}_x\text{I}_{3-x}$ perovskite after adding PbS colloidal quantum dots (CQDs) in $\text{CsPbBr}_x\text{I}_{3-x}$ films has been reported.⁷⁷ The crystal structure and the orientation of perovskites relative to PbS CQDs were investigated by high-resolution TEM. They observed the formation of a perovskite shell at high PbS CQD concentration, and there was no spacing difference between the core CQD and the CsPbBr_2I perovskite shell at $(1\bar{1}1)$ and (200) planes, indicating the epitaxially orientational alignment of $(1\bar{1}1)$ and (200) planes for both PbS CQDs and for the CsPbBr_2I [Fig. 2(a)]. Lattice mismatch increases as decreasing the ration of Br in $\text{CsPbBr}_x\text{I}_{3-x}$, generating a larger strain at interfaces.⁷⁷ It was also reported that the epitaxial growth of $\alpha\text{-FAPbI}_3$ phase was observed during its phase transformation from the hexagonal $\delta\text{-FAPbI}_3$ when it forms epitaxial heterostructure with $\text{FPEA}_4\text{PbI}_4$ layered perovskite.⁷⁶ After adding $\text{FPEA}_4\text{PbI}_4$ layered perovskites in FAPbI_3 perovskite films, TEM images [Fig. 2(b)] showed that the (002) plane of the layered perovskite was aligned with the (010) plane of the $\delta\text{-FAPbI}_3$ phase, and the larger interplanar spacing of the $\delta\text{-FAPbI}_3$ indicates the presence of tensile strain at the interface with the layered perovskite. Meanwhile, a semi-coherent interface between the layered perovskite and the $\alpha\text{-FAPbI}_3$ was observed, where the (111) plane of the grown $\alpha\text{-FAPbI}_3$ orientationally aligns with the (002) plane of the layered perovskite, implying that the heteroepitaxial growth of the $\alpha\text{-FAPbI}_3$ crystals occurs during the phase conversion process, and the compressive strain was applied to the interfacial $\alpha\text{-FAPbI}_3$ phase.⁷⁶

c. Interface (not epitaxy)/surface stress. Zhao *et al.* fabricated large-grained CsPbBr_3 perovskite films by two-step sequential deposition fabrication method and observed the compressive stress along the in-plane direction. The compressive stress is high enough to induce strain in CsPbBr_3 perovskite films. The compressive stress originated from lattice mismatch between PbBr_2 to CsPbBr_3 due to the fact that the lattice volume is enlarged by 2.18 times during the phase conversion from PbBr_2 to CsPbBr_3 perovskite.⁷⁸ In addition, lattice mismatch between perovskite lattices and large cations introduced on the surface of perovskites, like PEA^+ , GA^+ , also induces strain to perovskite films.

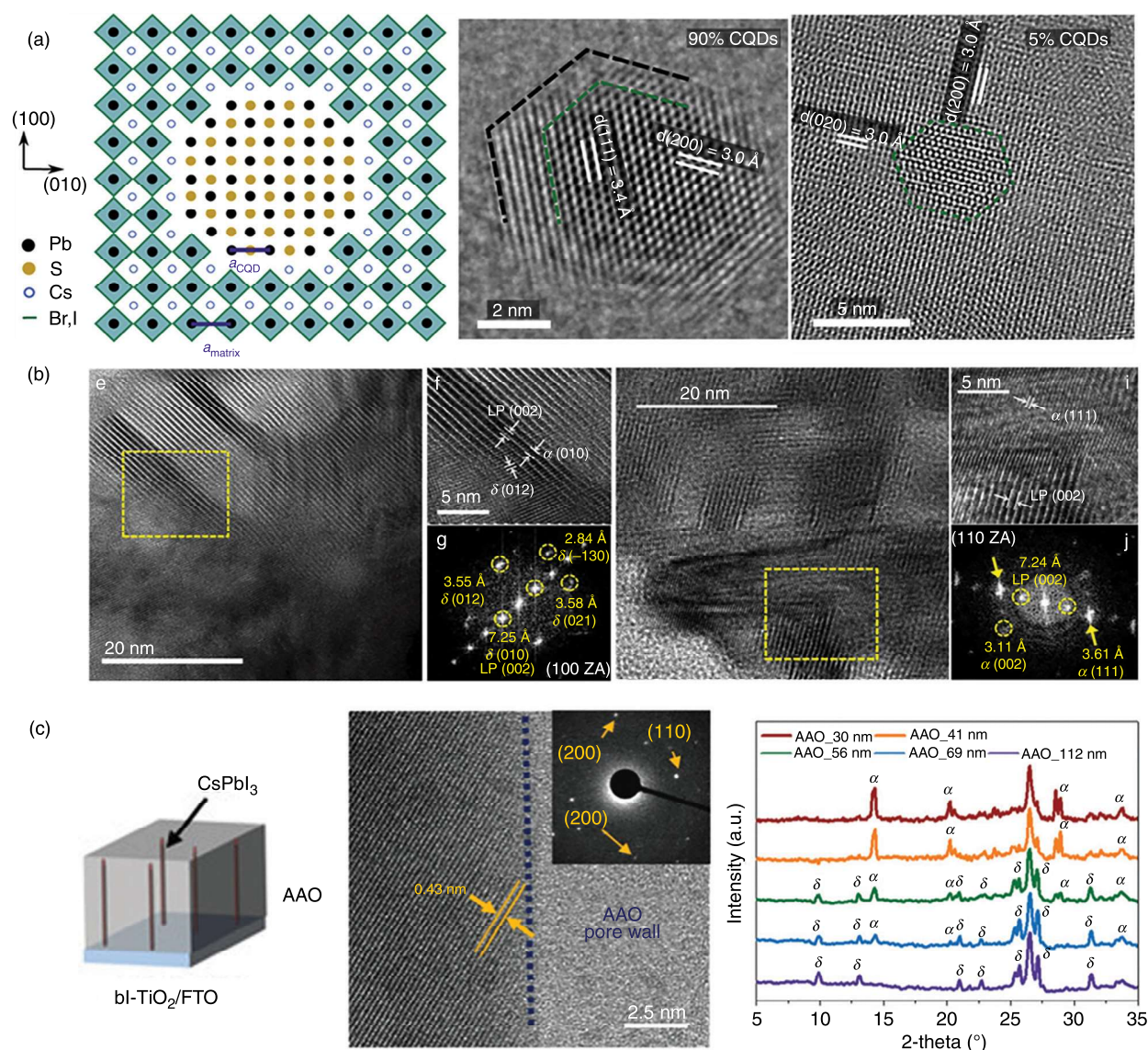


FIG. 2. (a) Schematic depiction of the atomistic model of a PbS QCD:perovskite lattice-anchored hybrid materials system and high-resolution TEM images of the lattice-anchored PbS QCD:perovskite hybrid materials at high (up) and low (down) CQD concentration.⁷⁷ Reproduced with permission from Liu *et al.*, Nature **570**, 96–101 (2019). Copyright 2019 Nature Publishing Group. (b) High-resolution TEM images and corresponding fast Fourier transform analysis of FAPbI₃ films incorporated with FPEA₄PbI₄ before (left) and after the phase conversion process (right).⁷⁶ Reproduced with permission from Lee *et al.*, Nat. Commun. **11**, 5880 (2020). Copyright 2020 Nature Publishing Group. (c) High-resolution TEM image of CsPbI₃ perovskite confined in an AAO template with a pore size of 41 nm (left) and XRD patterns CsPbI₃ perovskite thin films confined in AAO templates (right).⁸⁰ Reproduced with permission from Ma *et al.*, Small **15**, 1900219 (2019). Copyright 2019 Wiley-VCH.

409 The soft cation framework of large organic cations buffers the lattice
410 deformation under residual stress in perovskite films.⁷⁹

411 Ma *et al.* noted that strain was imposed on α -CsPbI₃ perovskites
412 when they were confined in vertically aligned nanopores of anodized
413 aluminum oxide (AAO).⁸⁰ As shown in Fig. 2(c), high-resolution
414 TEM showed that perovskite crystals were confined within 41 nm-size
415 pores of AAO template, and the (110) plane was sloped at an angle of
416 35.5° with respect to the AAO pore wall. XRD results exhibited a

reduce in the peak intensity (200)/(110) ratio, indicating enhanced
growth of the (110) plane while suppressing the growth of the (200)
plane. They thought that the compressive stress imposed by the pore
walls was imposed on the [010] and [001] directions of the perovskite
lattice, suppressing the growth of the (200) plane-parallel to the pore
wall. The compressive stress made the dominant growth orientation of
 α -CsPbI₃ change to the stress-free [100] direction. The strain magni-
tude is dependent on the nanopore size of the AAO template. External

mechanical stress-induced strain, by hydrostatic pressure and bending substrates, has also been reported.^{81–85}

In perovskite nanoparticles, strain mainly comes from its high surface tension due to the large surface-to-volume ratio. The tension and strain magnitude depend on the size of perovskite nanoparticles.⁸⁶ One the other hand, Zhao *et al.* used synchrotron radiation x-ray diffraction to analyze different shaped CsPbBr₃ nanocrystals with the same fabrication processes and observed the increasing trend in strain values of the nanocrystals: nanocube, nanoplate, nanowire. They thought that the strain reflected the mechanical response of CsPbBr₃ nanoparticles to the stimulus from surrounding liquid organic ligands, and the result was in good agreement with the nature that nanowires are easier than nanocubes for bending.⁸⁷ Size-dependent and/or shape-dependent strain in perovskite nanoparticles and its effect on nanoparticle properties and devices are interesting topics and need to be further understood in the future.

d. Ferroelasticity and the photostrictive effect. Some MHPs have been determined to be ferroelastic, which can change strain in perovskites with an intrinsic path. When an external stress is applied, the ferroelastic perovskite would dissipate the strain energy by forming twin structures.^{88,89} This effect makes the strain imposed by external stress difficult to determine and should be paid attention to during research. In addition, the photostrictive effect of halide perovskites has also been reported, and the photostrictive response was proportional to the light intensity.^{90,91} However, the photostrictive effect of perovskites has been raised to be an experimental artifact which can be caused by the thermal expansion from the photothermal effect was underestimated. To distinguish the contribution of strain from photostriction and thermal expansion under light in halide perovskites,

Chen *et al.* turned the light (100 mW.cm⁻² white LED) on and off when the device temperature was kept constant.⁶³ It has been found that switching the light between on and off conditions for 10 min has no influence on the position of XRD peaks of MAPbI₃ when temperature was kept constant. In addition, comparing the thermal expansion and photostriction on a millisecond timescale, it was still found the thermal expansion dominated the light-induced strain in MAPbI₃, with no photostriction detected within equipment sensitivity limitation.⁹²

e. Device encapsulation and operation. Photovoltaic (PV) modules need to be encapsulated. In the encapsulation process, a high temperature of > 100 °C is generally required to cure the encapsulant, and then assembled layers are pressed together in a laminator to remove air. During this process, global strain may be introduced into perovskite and other layers due to the difference in thermal expansion coefficients of different layers. In addition, pressure from the laminator can also cause the deformation of the materials.

In operation, the working temperature of solar cells varies with environmental conditions. The environmental temperature can vary from -40 °C in Arctic areas to 85 °C in desert areas. In addition, the average temperature in desert areas can be up to 40 °C during the daytime and fall to -4 °C during nighttime.^{93–96} The capability of solar cells to keep their integrity is generally examined in the temperature cycling test part of stability evaluation; however, their impact to the strain in perovskites and other function layers have not been studied yet. Besides, hail, snow, and wind in the environment and other external mechanical loads can also deform large solar panels. PV modules are mounted onto a support framework, resulting in the constraints of displacement and rotation of them. As shown in Fig. 3(b), a PV

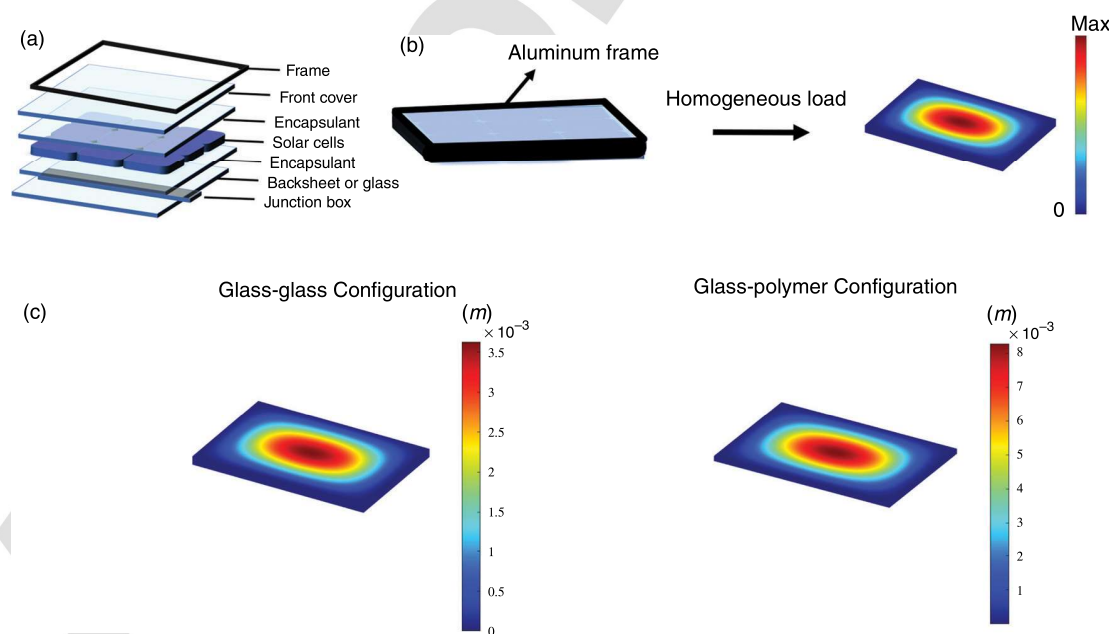


FIG. 3. (a) Structure of PV modules. (b) Displacement distribution on solar panels framed by perimeter under a homogeneously distributed load on the front cover. (c) Displacement distribution on glass-glass and glass-polymer solar panels framed by perimeter under 1000 Pa on the front cover.

module is fixed on a metal framework by framing perimeters where a homogeneous distributed load is applied on the front cover of PV modules to simulate snow or wind. Using finite element simulation by MATLAB, we show that maximum strain occurs in center of the PV modules, and there is no strain at the constrained region.

Different supporting systems (rigid and flexible) should also have varied effect on strain in PV modules. For flexible frames, strain also occurs in the attached areas in PV modules due to higher flexibility and lower constraint on deformation.⁹⁷ As shown in Fig. 3(c), strain in glass-polymer PV modules is larger than that of glass-glass PV modules when applying the same homogeneously distributed load (1000 Pa). What is more, strain in PV modules could come from the weight of the module itself. When only the weight of the module is considered, strain in glass-glass PV modules is larger than that of glass-polymer PV modules. More simulation can be found elsewhere on thermal and mechanical stress-strain in Si PV modules.^{98,99} The research on strain in perovskite solar cells still at its early stage, which focused on strain engineering in perovskite films. More research at a later stage is needed to find out the strain generation and distribution in perovskite PV modules and their impact.

Table I lists the strain, its magnitude, and influence in metal halide perovskites from recently published experimental work.

B. Impact of strain on properties of perovskites

1. Influence of strain on perovskite structures

a. Phase transition. Strain engineering of perovskites could induce the deformation of the crystal structure or phase transitions by distorting the inorganic framework. In the strained epitaxial growth of α -FAPbI₃ films on lattice-mismatched single crystal perovskite substrates, reciprocal space mapping of strain-free and strained α -FAPbI₃ thin films showed that the increase in the tetragonality of the lattice is evident as the compressive strain increases.⁷³ Under hydrostatic pressures, most of perovskite single crystals, like MAPbI₃, MASnI₃, FAPbI₃, CsPbI₃, CsPbCl₃, (PEA)₂PbBr₄, have been reported to undergo phase transition processes, then become amorphous under higher pressures (e.g., 4.1 GPa for FAPbBr₃ single crystal).^{102,103} The magnitude of the pressure needed to induce phase transition and amorphization is different for halide perovskites with different compositions and lattice symmetries, which have different bulk moduli and elastic moduli.

b. Thermodynamics and kinetics of perovskite stability. Thermodynamics of phase stability. Modulating strain is a promising strategy to stabilize photoactive perovskite phases. In perovskites with tolerance factors out of the range 0.8 to 1, local strain can be changed by incorporating foreign ions, successfully establishing an energetically stable photoactive alloyed perovskite.³⁶ In addition, it has also been observed that the freshly fabricated, black photoactive pure phase perovskite films can be stable on substrates at room temperature for a few minutes. However, once they were scraped from the substrate, they would turn into yellow phase immediately.^{34,71} Compared to the strain-free perovskite powders, perovskite films on the substrate have a biaxial tensile strain due to the thermal expansion coefficient differences between the perovskite and the substrate. In CsPbI₃ perovskite, the introduction of $\sim 1\%$ in-plane biaxial strain leads to different free energy changes for the orthorhombic γ -phase ($\Delta E = 4$ meV) and

hexagonal δ -phase ($\Delta E = 31$ meV), making the energy difference promoting the γ -to- δ transition decrease from 85 meV to 58 meV, thus improving the phase stability of γ -phase CsPbI₃ [Fig. 4(a)].⁷¹ Meanwhile, the compressive strained epitaxial α -FAPbI₃ thin film exhibits long-lasting phase stability at room temperature.⁷³ As shown in Fig. 4(b), the sub-100 nm epitaxial α -FAPbI₃ thin film with in-plane 2.4% compressive strain is stable for at least 360 days at room temperature. In contrast, the strain-free α -phase FAPbI₃ immediately turns into the yellow δ phase in only one day. Chen *et al.* proposed two possible mechanisms for the stability of epitaxial α -FAPbI₃ films: the interfacial energy of the α -FAPbI₃/MAPbCl_xBr_{3-x} single crystal substrate is lower than that of the δ -FAPbI₃/MAPbCl_xBr_{3-x} single crystal substrate; the compressive strain in the epitaxial α -FAPbI₃ neutralizes the effect of an internal tensile strain, which would induce the formation of vacancies and subsequent phase transition.

Phase transition energy barrier. The influence of strain on the energy barriers for the phase transition between the α -FAPbI₃ and δ -FAPbI₃ was calculated based on the density functional theory (DFT). The calculations confirmed the existence of a potential barrier for the phase transition between α -FAPbI₃ and δ -FAPbI₃.¹⁰⁴ Lee *et al.* found that strain increases the phase transformation energy barrier height of α -phase to δ -phase, and when the FAPbI₃ interlayer spacing decreases from 15.48 Å toward the 15.26 Å, the energy barrier height increased by ~ 0.15 eV from the DFT calculations [Fig. 4(c)].⁷⁶ The increase in energy barrier between α - δ phase will be beneficial for the thermodynamic stability of the α -phase at room temperature. In conclusion, strain engineering can stabilize photoactive perovskite phase.

Ion migration. In strained halide perovskites, local tensile strain reduces the stability of the photoactive perovskite through strain relaxation by the formation of point defects.³⁶ These point defects may be the energetic active sites to react with water and oxygen molecules, thereby accelerating the degradation of perovskites. In addition, tensile strain will reduce the stability of perovskite by accelerating the ion migration, even though it can stabilize α -FAPbI₃ perovskite phase by suppressing the phase conversion to δ -phase. Zhao *et al.* directly measured the ion migration activation energy by temperature conductivity of perovskites under different strain status and verified that the tensile strain in MHPs reduces the activation energy of ion migration.³⁴ Figure 5(a) shows schematic diagram of the different strained MAPbI₃ films by bending substrates. The in-plane biaxial tensile strain in the flat film is about 0.47%. The films were bent in a convex shape to increase the strain to 0.62% or in a concave shape to reduce the strain to 0.2%. When exposing the encapsulated strained film to ~ 50 mW/cm² illumination at 65 °C, the films with 0.63% tensile strain had large areas turned yellow with the appearance of strong PbI₂ peaks, whereas the films with the almost zero tensile strain remained mostly black without any appearance of the PbI₂ peak after 500 h illumination. The accelerated degradation by strain is related to the change of ion migration under strain. In the dark, the activation energies for ion migration are 0.29, 0.39, and 0.53 eV, respectively, and 0.046, 0.074, and 0.083 eV, respectively, under 25 mW/cm² white illumination when tensile strain are 0.62%, 0.47% and 0.2%, respectively. The result conclusively shows that the perovskite films with larger tensile strain have smaller ion migration activation energy in both dark and under illumination conditions. The ion migration accelerates the decomposition of perovskites.

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TABLE I. Strain and its magnitude in metal halide perovskites from published experimental work.

Perovskite	Strain origin	Strain magnitude and state (tensile strain +, compressive strain -)	Strain type	Strain effect	Ref.
MAPbI ₃ film	Thermal expansion/ bending	0.2%–0.62%	Global	Thermal expansion induced in-plane tensile strain in perovskite films; Tensile strain decreased the activation energy of halide migration and accelerated the degradation of perovskites.	34
MAPbI ₃ film	Thermal expansion	–0.30%	Global	Strain patterns have a complex heterogeneity across multiple length scales; strain has a complex local heterogeneity with a magnitude of 0.1–0.2%; Lattice out-of-plane compressive strain is directly associated with enhanced defect concentrations and non-radiative recombination.	65
CsPbBr ₃ film	Thermal expansion	–1.02%	Global	Out-of-plane strain measured via nano-XRD varies between –0.8 and –1.6%; Nanoscale residual strains negatively affect the stability of perovskites.	66
CaPbI ₃ film	Thermal expansion	1%	Global	Cooled CsPbI ₃ film from 300° to 100 °C introduced an in-plane biaxial tensile strain of ~1%; Strain stabilized black perovskite phase due to different energy penalties for two phases; Black phase transformed to the yellow phase through strain release.	71
CsPbI ₂ Br film	Thermal expansion	–1.5%–1%	Global	The activation energy of halide ion migration increased, and phase separation was suppressed under compressive strain; PCE enhanced from 14.8% (tensile strain), 15.5% (strain free) to 16% (compressive strain); Compressive-strain and non-strain devices retained 96 and 80% of their initial PCEs after 1000 h of heating at 85 °C.	72
Cs _{0.05} MA _{0.16} FA _{0.79} Pb(I _{0.83} Br _{0.17}) ₃ film	Thermal expansion		Global	Thermal expansion induced in-plane tensile strain and accelerated the degradation of perovskite films;	35
FAPbI ₃ film	Lattice mismatch	–2.4%–0	Global	High film stress increased mechanical fragility of perovskite. Compressive strain stabilized black FAPbI ₃ phase over 360 days at room temperature; Strain modulated bandgap of FAPbI ₃ ; Compressive strain enhanced the carrier mobility prominently.	73
CsPbBr ₃ nanowire	Lattice mismatch		Global	Lattice distortion originated from heteroepitaxial mismatch, accentuated by thermal expansion coefficients differences; Strain modulated bandgap and caused PL peak shift of nanowire.	74
FAPbI ₃ film/ FPEA ₄ PbI ₄	Lattice mismatch		Local	The layered perovskite-templated epitaxial crystal growth was induced during the phase transformation of δ - α -phase; Tensile strain is existed at the interface between δ - and	76

TABLE I. (Continued.)

Perovskite	Strain origin	Strain magnitude and state (tensile strain +, compressive strain -)	Strain type	Strain effect	Ref.
CaPbI ₃ film	AAO pore wall -stress	-2.5%-0	Global	layered perovskite; after phase transition process, compressive strain was induced in the interfacial α phase. Strain increased the phase transition energy barrier, retarding the phase conversion kinetics.	80
				Compressive strain decreased surface formation energy of the α -phase; Compressive strain stabilized α -phase over three months under ambient conditions;	
CsPbBr ₃ film	Lattice mismatch	Compressive stress	Global	Compressive strain extended the carrier lifetime. Precise stress control of CsPbBr ₃ film by controlling the crystallization temperature of PbBr ₂ film; Reduced defect-induced charge recombination and enhanced charge transfer under suitable stress.	78
FAPbI ₃ film	Ion size mismatch		Local	Strain relaxation in FAPbI ₃ by forming point defect; Introducing smaller ions, MA/Cs or Br/Cl stabilized perovskite phase and enhanced film stability.	36
(FAPbI ₃) _{0.85} (MAPbBr ₃) _{0.15} film	A site incorporation	In-plane strain	Global	A site alloying at the surface lattice of perovskite film leads to relaxation of interfacial residual stress; Stress relaxation reduced traps on the surface and enhance stability of perovskite films.	58
PbS CQD: CsPb(IBr) ₃ film	Lattice mismatch		Local	The lattice match between QDs and α -phase suppressed the transition to the undesired δ -phase; Perovskite films remained stable for more than six months at ambient conditions; Carrier mobility was twofold due to a reduced energy barrier for carrier hopping.	77
(CH ₃ (CH ₂) ₃ NH ₃) ₂ (CH ₃ -NH ₃) _{n-1} PbI _{3n+1} film	Bending	0-1.18%	Global	Tensile strain increases the optical bandgap at a rate of 13.3 meV/%.	85
(PEA) ₂ PbI ₄ single crystal	Hydrostatic pressure	Compressive strain	Global	Ultrabroad tunability of ~ 320 meV by a moderate pressure ranging from 0 to 3.5 GPa.	100
MAPbBr ₃ single crystal	Thermal expansion	-0.3%-0.3%	Global	Crystal lattice can strain, relax, or compress as the annealing temperature varies; HOMO levels changed under different strain; The carrier mobility, photocurrent, charge carrier lifetime enhanced under 60 ± 55 °C.	101

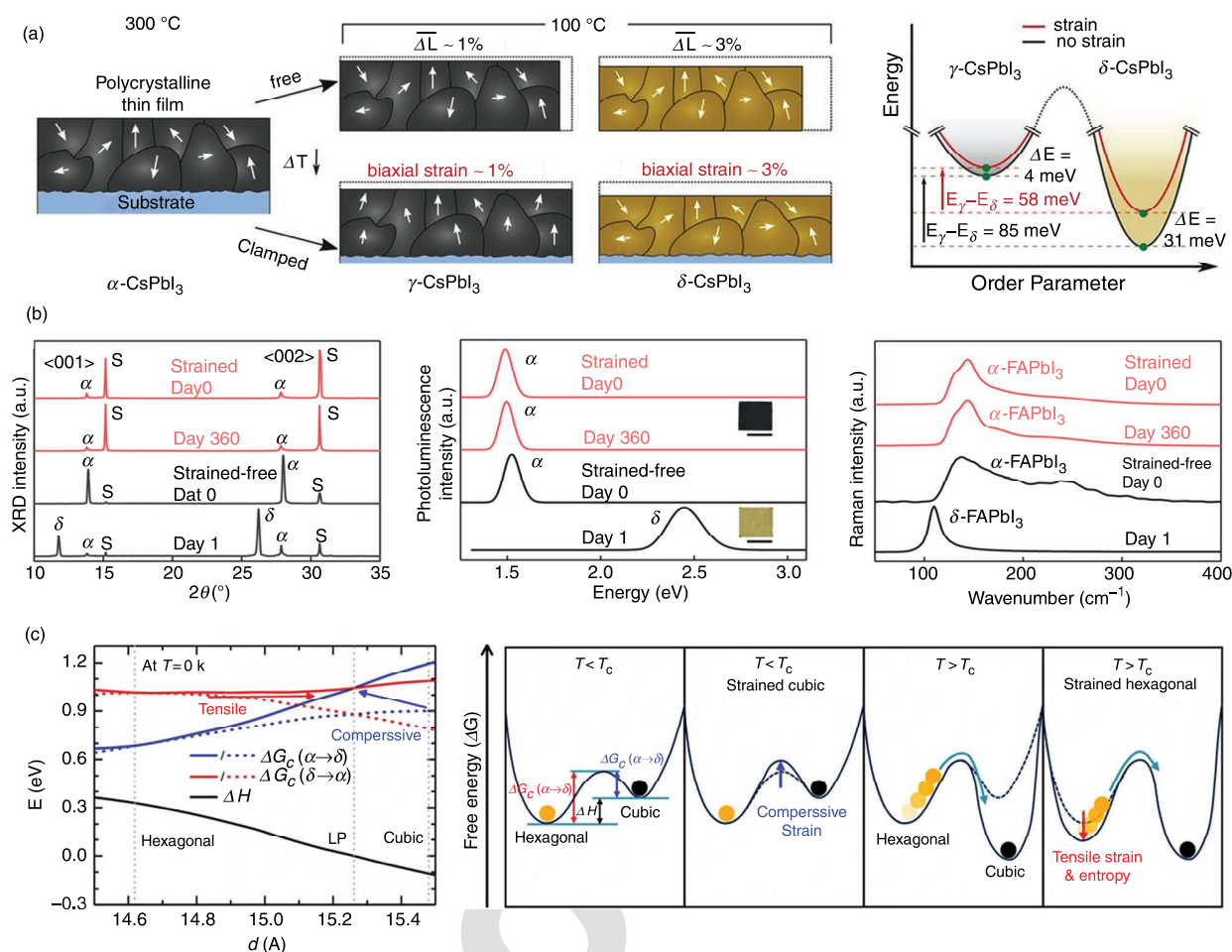


FIG. 4. (a) *Ab initio* energy diagram of the black and yellow CsPbI₃ phases with and without in-plane biaxial strain.⁷¹ Reproduced with permission from Steele *et al.*, Science **365** (6454), 679–684 (2019), Copyright 2019 American Association for the Advancement of Science. (b) Phase stability comparison of strained FAPbI₃ film and unstrained FAPbI₃ film.⁷³ Reproduced with permission from Chen *et al.*, Nature **577**, 209–215 (2020), Copyright 2020 Nature Publishing Group. (c) DFT-calculated free energy barriers (ΔG_{cs}) for phase conversion (left) and schematic free energy diagrams for the δ - and α -phased FAPbI₃ at compressive strain condition (right) and schematic free energy diagrams for the hexagonal and cubic phased FAPbI₃ at different temperatures and strain condition.⁷⁶ Reproduced with permission from Lee *et al.*, Nat. Commun. **11**, 5880 (2020). Copyright 2020 Nature Publishing Group.

The ion migration will lead to the phase segregation in mixed halide perovskites, which is detrimental to perovskite material stability. Liu *et al.* obtained near strain-free colloidal PbS quantum dots (CQDs)-CsPbBr₂I perovskite interface. They observed that phase segregation occurred in pristine CsPbBr₂I perovskite films within 30 min after annealing in air at 200 °C. However, this was largely suppressed when PbS CQDs are integrated in CsPbBr₂I at a concentration above 6%, and no film degradation was observed after 5 h.⁷⁷ The intensity loss in absorbance and the shift in the absorption edge of unencapsulated CQDs-CsPbBr_xI_{1-x} after 5 h of annealing in air (x is the Br content) are shown in Fig. 5(b). For PbS CQD: CsPbBr₂I ($x \sim 66\%$) samples in which near zero lattice mismatch is achieved at the interface of PbS CQDs-CsPbBr₂I, film stability shows a gradual improvement with increasing CQD concentrations. Ehrler *et al.* found that

when the hydrostatic pressure applied to the perovskite film was increased to 0.3 GPa,⁸¹ the formation rate of iodide-rich and bromide-rich phases in MAPb(Br_xI_{1-x})₃ decreased by two orders of magnitude. The results are consistent with calculational work about the tendency of activation energy for ion migration with strain. The migration barrier of ions increases under compressive strain and decreases under tensile strain.¹⁰⁵ Compressive strain shortens the length of the Pb–I bond and enhances the interaction between Pb and I atoms, making it difficult for I ions to escape from the lattice. As the activation energy for ion migration increases, phase segregation was suppressed and the I-vacancy concentration in the perovskite decreases.¹⁰⁶ Notably, material stability can decrease significantly when the elastic strain energy in materials is big enough to induce the formation of misfit or dislocation.^{107,108}

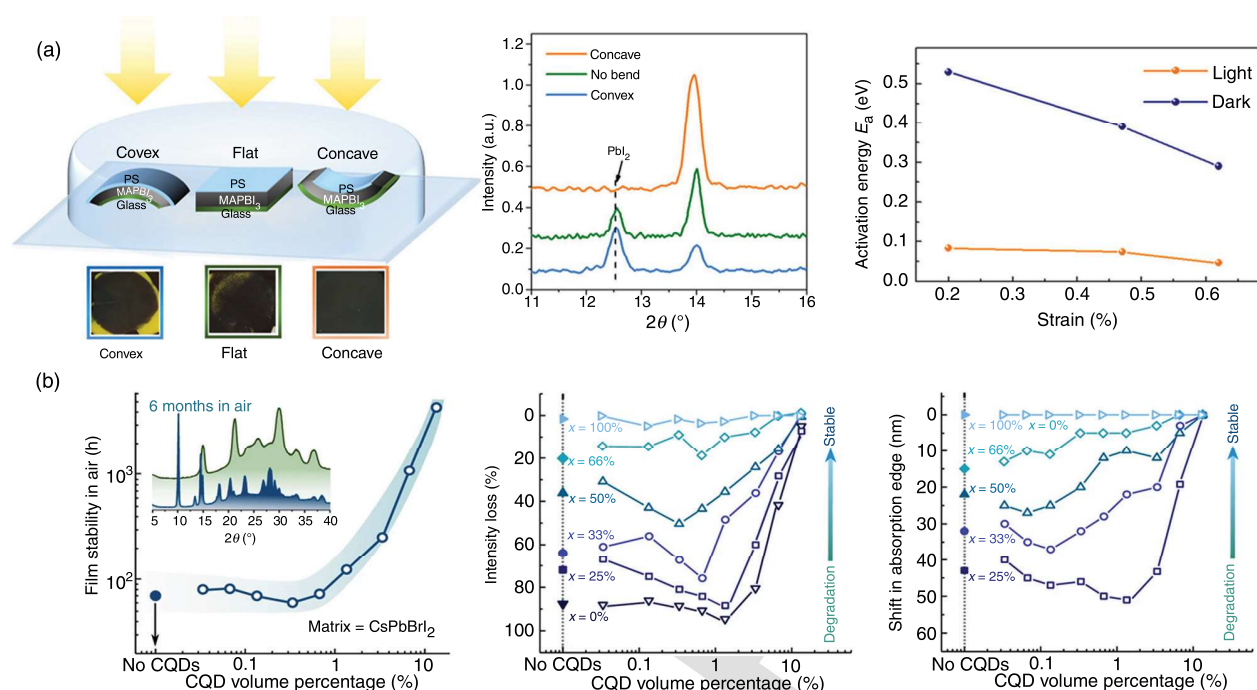


FIG. 5. (a) Schematic illustration of the experimental setup applying different strains and resulting photographs of the corresponding MAPbI₃ films after 500 h of illumination (left); out-of-plane XRD patterns of the MAPbI₃ films with different strains by bending (center) and activation energy of ion migration as a function of the strain level in the MAPbI₃ films.³⁴ Reproduced with permission from Zhao *et al.*, *Sci. Adv.* **3** (5616), eaao5616 (2017). Copyright 2017 American Association for the Advancement of Science. (b) The intensity loss in absorbance (left) and the shift in the absorption edge (right) after 5 h of annealing in air. *x* is the Br content. Lattice mismatch increases as decreasing Br content and, thus, a larger strain is generated at interfaces; a lower PbS CQD concentration results in more perovskite layers between neighboring PbS CQDs and consequently increases the effects of strain.⁷⁷ Reproduced with permission from Liu *et al.*, *Nature* **570**, 96–101 (2019). Copyright 2019 Nature Publishing Group.

2. Influence of strain on optoelectronic properties of perovskites

a. Band structure and carrier mobility. Alteration in band structure and carrier mobility with strain have been observed in perovskite materials. In most MHPs, the Pb–I orbital coupling contributes directly to the nature of valence and conduction band edges. The A cations do not contribute directly to the formation of band edges, but their size will influence the Pb–I orbital coupling, thus influencing the valence and conduction band edges indirectly. The valence band maximum (VBM) of perovskite is mainly derived from the strong antibonding coupling between s orbital of Pb and p orbital of I, and the conduction band minimum (CBM) is mainly derived from the coupling of the Pb p orbital with negligible I.^{3,109} Under a tensile strain, the elongation of Pb–I bonds and/or the reduction of Pb–I–Pb angles will decrease the antibonding overlap between the Pb 6s and I 5p orbitals, causing the downshift of VBM and thus the broadening of the bandgap. Under a compressive strain, the shortened Pb–I bonds will enhance the coupling between the Pb s and I p orbitals and lift the VBM, resulting in a reduction of the bandgap. With the further increase in the compressive strain, the decrease in Pb–I–Pb bond angles and resulting inorganic octahedral tilting start to dominate, which will weaken the Pb 6s and I 5p orbital overlap, thereby downshifting the VBM and increasing the perovskite bandgap.^{106,110,111} Cases where strain alters the bandgap have been reported. When the hydrostatic

pressure of 2.1 GPa was applied to the α -FAPbI₃ single crystal, its bandgap reduced from 1.489 eV to 1.337 eV.¹¹² Tu *et al.* applied in-plane uniaxial tensile strain to (CH₃(CH₂)₃NH₃)₂(CH₃–NH₃)_{n–1}Pb_nI_{3n+1} 2D perovskite flakes and found that its bandgap increases as the strain increases, and the strain response of bandgap could be as high as 13.3 meV for one percent of strain.⁸⁵ The photoluminescence peak of sub-100-nm epitaxial α -FAPbI₃ thin films gradually shifted from about 1.523 eV at 0% strain to about 1.488 eV at –2.4% strain, corresponding to a reduction of about 35 meV in the bandgap.⁷³ Clearly, the changes in bandgap under strain are different and dependent on the composition of the perovskite.

Change of the carrier mobility as a function of strain has also been studied.^{73,113,114} Figure 6(a) shows the calculated effective mass (*m*^{*}) of electron and hole of a α -FAPbI₃ perovskite and the band structures of the perovskite with the strains of 3%, 0%, and –3%.⁷³ The effective mass of electron (*m*_e^{*}) remains basically unchanged with the change in strain, while the effective mass of hole (*m*_h^{*}) decreases considerably with the increase in the compressive strain. The reduced *m*_h^{*} under compressive strain enhances the hole mobility until the compressive strain is up to –1.2%, as measured from Hall effect measurements and time-of-flight measurements in Figs. 6(b)–6(c).⁷³ The sharp drop in hole mobility above –1.2% strain is attributed to the higher dislocation density at higher strains.

In MHPs, the spin–orbit coupling effect contributes strongly to the band splitting in perovskites at different strain due to the existence

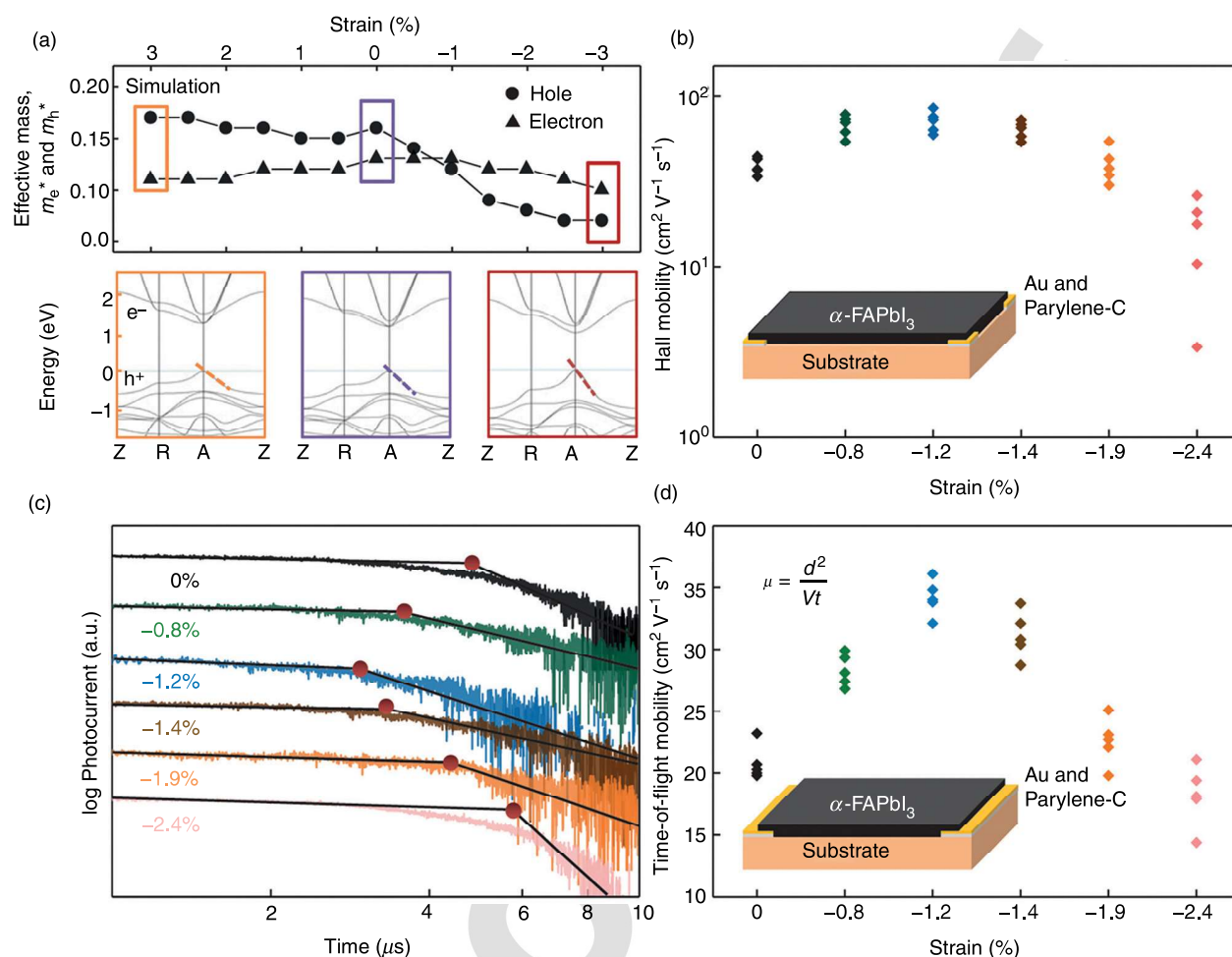


FIG. 6. (a) Calculated effective masses of the carriers at different strains, and electronic band structures under three strain levels (3%, 0%, and -3%). (b) Hole mobilities by Hall effect measurements under different strain. (c) Transient photocurrent curves of the epitaxial α -FAPbI₃ under different strains. (d) Plots of calculated carrier mobilities as a function of the strain magnitudes.⁷³ Reproduced with permission from Chen *et al.*, Nature **577**, 209–215 (2020). Copyright 2020 Nature Publishing Group.

of the heavy Pb or Sn atoms.^{115,116} Strain induces transition between direct and indirect bandgap in perovskite due to the different spin-splitting behaviors of CBM and VBM.^{117,118} Ghosh *et al.* used *ab initio* simulations to investigate the Rashba-splitting effect and the structural property of FA_{0.75}Cs_{0.25}PbI₃ under hydrostatic pressure and proposed that there was a direct-indirect bandgap transition in FA_{0.75}Cs_{0.25}PbI₃ under 3 GPa, and the resulting indirect bandgap was 5–7 meV narrower than the direct gap.¹¹⁵ Differently, an indirect-direct bandgap transition was observed in MAPbI₃ single crystal at 325 MPa hydrostatic pressure and the position of the indirect transition was 60 meV below the direct transition. They thought the reduction of Rashba splitting derives from the reduction in local electric field around the Pb atom under pressure.¹¹⁹

b. Defects. In strained perovskites, the enhancement of Pb–I interaction under compressive strain increases the difficulty for I ions to escape from the potential well of Pb atoms, increasing the I

migration barrier, which reduces the density of I vacancies and under-coordinated Pb. Conversely, the weakening of Pb–I interaction deriving from the lengthening of Pb–I bonds and shrinking of I–Pb–I bond angles may increase the density of I vacancies in perovskites. In perovskite band structures, strain pushes up/down VBM, which will change the trap states. Compressive strain causes the ascendance of the VBM, leading the trap states already existing in the sub-gap close to VBM to become shallower-level defects.¹⁰⁶ Therefore, non-radiative recombination of carriers reduces, and carrier lifetimes are improved. Conversely, the trap states shift to a deeper energy level as the VBM shifts downward, increasing non-radiative recombination.

Photoluminescence (PL) spectroscopy is one of the most convenient techniques to characterize the influence of strain to the charge recombination properties of perovskites and thus how strain changes defects in perovskites. In strained perovskites, the PL intensity and carrier lifetime were shown to change significantly.^{65,106,120} Kong *et al.* reported that the compressed MAPbI₃ single crystals exhibited a

TABLE II. Materials of the PV laminate used in the FEM model with the applied material model and thickness.

Layer	Materials	Thickness (mm)	Young's modulus (GPa)	Poisson's ration (ν)
Backsheet	PVF-PET-PVF	0.35	3.5	0.29
Encapsulant	EVA	0.45	0.11	0.49
Solar cell	Monocrystalline Si	0.2	130	0.28
Front cover	Glass	3.2	73	0.23

notable red-shift of its absorption edge under ~ 0.3 GPa hydrostatic pressure, and the bandgap narrowing triggered a 70% to $\sim 100\%$ increase in carrier recombination lifetime.¹⁰⁶ Jones *et al.* combined synchrotron scanning XRD measurements and local time-resolved PL measurements to study MAPbI₃ films and revealed that local strain (tensile strain along in-plane direction) led to an increase in defects such as halide vacancies that are associated with local non-radiative decay. They quantified the trap density with a kinetic model and found that the local strain increased the trap density from $1 \times 10^{16} \text{ cm}^{-3}$ to $7.5 \times 10^{16} \text{ cm}^{-3}$.⁶⁵ Notably, their results did not exclude the influence of grain boundaries, where defect concentration is higher than that of grain interior. Furthermore, in perovskite nanoparticles, Zhao *et al.* observed that much bigger strain results in more strain-induced defects, leading to lower PL intensity and PL quantum yields (PLQYs) of nano-scale colloidal CsPbBr₃ perovskite materials.⁸⁷

In addition, in polycrystalline perovskite films, strain was reported to be responsible for the formation of deep trap states and higher non-radiative recombination rate at grain boundaries. Several early calculations based on density functional theory reported that grain boundaries do not introduce deep gap states and are electrically benign,^{121,122} which is, however, against the experimental observations in the field. PL intensity was generally lower at grain boundaries, and grain boundaries exhibited a faster nonradiative decay.¹²³ Hundreds of passivation molecules have been developed to reduce the deep trap densities.¹²⁴ After passivation, grain boundaries showed high luminescence efficiencies.¹²⁵ Yan *et al.* considered the impact of the change of bond length or lattice constant at the grain boundary areas on the trap states. Their calculation found that the compressive strain with an increased I-I coupling strength at grain boundaries pushed the I-I antibonding states into the forbidden gap, making iodide interstitial to be deep defect states.¹²⁶ Park *et al.* calculated the energy levels of iodine interstitial defects at CsPbBr₃ grain boundaries. They found that when the I-I bond was lengthened at the grain boundaries, the I_i^+/I_i^- levels lowered in energy, making I_i^+ level deeper states with respect to the conduction band edge and I_i^- defects less detrimental than those in the grain interior.¹²⁷

IV. SUMMARY AND OUTLOOK

In summary, strain engineering is a powerful and promising method to control the properties of perovskites. Under strain, the changes in lead-halide bond lengths and halide-lead-halide bond angles will lead to the lattice shrinkage/expansion, or inorganic octahedra framework tilting and lattice rotation in the perovskite. Therefore, strain engineering can undoubtedly be applied to modulate the band structure and carrier dynamics. Meantime, the strain in perovskites will decrease the energy difference and increase the energy barrier between the perovskite phase and non-perovskite phases, thereby

stabilizing the perovskite phase. Strain changes the perovskite material stability due to changes in activation energy of ion migration and trap state energy level. Especially, compressive strain in perovskites increases the activation energy of ion migration, which will hinder the ion migration, thereby inhibiting phase segregation in mixed-halide perovskites.

There are still many open questions to be answered by the perovskite community concerning strain. The first question is about strain relaxation dynamics. Strain in perovskites would eventually be released with the generation of defects such as dislocations or grain boundaries. The second question to be answered is about the strain distribution on microscale. Strain may be inhomogeneous across the halide perovskite films, and the inhomogeneous distribution of strain on individual grains or across the films may lead to heterogeneity in carrier transport and recombination. Third, there is not enough study yet of how strain is introduced in the perovskite materials. Clearly the solvent evaporation process and thermal treatment would impact the strain formation, and even the solar panel encapsulation process may also introduce additional global strain due to the pressure and high temperature to be applied. Finally, strain would also be induced in devices in operation due to the changes of the environmental conditions. Therefore, the development of applicable methods to understand the strain-related phenomenon is important for the development of efficient and stable perovskite solar modules with high reliability.

Experiment and Methods

The simulation of strain distribution. The simulation was conducted by MATLAB. As a first step, we input the geometry of PV modules including different layers using geometric primitives, and then the geometry is discretized into a collection of finite element mesh using tetrahedral elements in 3D. Here, each layer is simulated as isotropic material, and the mechanical properties of them are shown in Table II. Boundary conditions are defined according to the PV installation way. In our case, the PV panel was framed at four edges and the mechanical pressure load test with 1000 Pa. At the end, displacement of PV modules was calculated by the partial differential equations (PDE). The PDE toolbox provides functions for solving structural mechanics, heat transfer mechanical deformations, fluid flow, and more.

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794 DATA AVAILABILITY

795 The data that support the findings of this study are available
796 from the corresponding author upon reasonable request.

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